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Optical Index Prism Sensitivity of Surface Plasmon Resonance Imaging in Gas Phase: Experiment vs. Theory

Jonathan S. Weerakkody,[†] Sophie Brenet,[†] Thierry Livache,[‡] Cyril Herrier,[‡]
Yanxia Hou,[†] and Arnaud Buhot^{*,†}

[†]*Univ. Grenoble Alpes, CEA, CNRS, IRIG, SyMMES, 17 Rue des Martyrs, 38000
Grenoble, France*

[‡]*Aryballe Technologies, F-38000 Grenoble, France*

E-mail: arnaud.buhot@cea.fr

Abstract

Recent advances in SPR-imaging detection in gas phase have led to the development of opto-electronic noses (opto-eNs) requiring the need for optical sensitivity characterization of such devices. Understanding of the optical contributions will have an implicit relevance on sensitivity enhancement of SPR-imaging in gas phase valuable to improve the performance of opto-eN and potentially open new applications as gas sensors. In this paper, we analyzed the optical contributions to the sensitivity of the SPR imaging prisms and potential insights into their contributing factors. We established a characterization method for the SPR prism sensitivity that is independent of the carrier gas considered. Then, by using this sensitivity parameter, the influence of two different kinds of adhesive layers, Cr and Ti, of the gold coated prisms were studied. Furthermore, we considered a theoretical model to rationalize our experimental results, which demonstrated the relevance of surface topography on the optical index

sensitivity. Those surface topographies were characterized experimentally and were implemented in the model free from any additional fitting parameters using a modified Maxwell-Garnet theory. Finally, the model was shown to predictively assess the experimentally measured effects of temperature on the prism sensitivity.

Introduction

Surface Plasmon Resonance (SPR) is an optical technique widely used in biosensor development for the sensing of chemical and biological compounds.^{1,2} The effectiveness of this technique can be attributed to its high sensitivity, real-time monitoring, label-free, and high throughput analysis. SPR based sensing techniques have been studied extensively over the past two decades for biomolecular interaction analysis in liquid phase. These SPR biosensors are based on various interrogation techniques, namely: angular, wavelength, phase, polarization and intensity.³ Intensity interrogation based SPR allows for an interrogation of the full surface of the prism by a camera also known as SPR imaging and is particularly interesting due to its multi-parametric detection capabilities. In this study, we will be focusing on this interrogation technique for gas phase analysis where the intensity of the reflected light will be referred to as its reflectivity.

As mentioned, SPR imaging systems are mostly used in liquid based affinity sensing.² However, other interrogation techniques such as angular interrogation have been adapted for gas phase sensing in several studies over the years.⁴⁻⁶ A recent article published by Brenet *et al.* highlights, for the first time, the efficiency of SPR imaging for the detection and discrimination of Volatile Organic Compounds (VOCs) in gas phase.⁷ Such a SPR imaging system has demonstrated great promise for a novel opto-electronic nose (opto-eN).⁷⁻¹⁰ Among its many advantages over existing eN systems, SPR imaging detection provides multiplexing capabilities allowing for the simultaneous monitoring of a large sensor array in real time. Furthermore, enhanced discriminatory capabilities can be seen through the temporal response of reflectivity changes, allowing for the extraction of multiple defining parameters,

such as equilibrium and adsorption and desorption kinetic responses for the generation of robust VOC fingerprint patterns.^{7,11} In addition to high selectivity, eNs are also associated with high sensitivities showing low limit of detection (LOD), for certain VOCs, comparable to a human nose.⁹ Sensitivity enhancement remains a pertinent interest as it would not only improve the detection limits for trace levels of VOCs but also aid in discriminatory purposes by increasing contrast of the aforementioned fingerprints. In response to this necessity, it is important to first characterize such SPR imaging systems. This process involves the contribution of two major aspects, namely, the optical and chemical contributions to the system sensitivity. The chemical contribution is attributed to the biomolecular interactions between the VOCs and the obtained sensing surfaces; either with semi-conductor surfaces,¹² polymer layers¹³ or surface functionalized with biomolecular receptors.^{7,14,15} In comparison, the optical contribution involves the SPR phenomenon itself and depends on the device parameters such as wavelength, temperature and metal film thicknesses. Before focusing on improving the chemical performances by selecting the optimal receptors for VOCs detection, it remains crucial to first optimize the experimental set-up and particularly the SPR prism coatings in terms of optical performances.

In this study, we will be focusing on the optical contribution to the systems' sensitivity. Thus, before the preparation of the sensor array on the SPR imaging prisms, they need to be optically characterized. A robust technique referred to in this paper as the sensitivity parameter approach was established as a performance measurement for the SPR imaging set-up. This measure was shown to be independent of the carrier gas used allowing for prism calibration and further compensation for environmental variations during *in-situ* or *on-field* measurements. Furthermore, using this performance parameter, the prism materials and fabrication contributions to these experimentally derived values were evaluated and compared with a theoretical model. Two different adhesive layers, Chromium (Cr) and Titanium (Ti), were studied for their impact on the overall performance. The subsequent deposition of the gold (Au) layer on the glass prism led to further surface topography considerations, which

were analyzed using Atomic Force Microscopy (AFM). Even though there have been previous studies focused on surface plasmon enhancement, by reducing surface roughness, via processes such as annealing.¹⁶ It remains a challenge, specifically, trying to understand the contributions of these surface topographies. We demonstrated that the surface topography (the z -direction surface roughness and x -, y -direction lateral contributions) of the Au layer played a major role in the sensitivity losses due to damping effects. This was tested using the AFM measurements of the surface topography, where a new approach was validated for the incorporation of these surface topography damping effects into the theoretical model. A well known mixing formulae was used for an effective layer accounting for the roughness of the Au layer which was experimentally validated free from any fitting parameters. Finally, the impact of 3-dimensional surface topographies on the optical index sensitivity were confirmed with a better understanding of their possible implications. In consequence, the theoretical model was predictive for the temperature variation of the performances; thus, being useful in proposing recommendations for sensitivity improvements and drift corrections for the opto-eN. By decoupling this optical temperature contribution it would be possible to further understand the complexities of this compounded temperature effect on the subsequently immobilized receptors.

Theoretical Considerations

For the implementation of the theoretical model a multi-layer Kretschmann configuration was employed mimicking the experimental system being used.¹⁷ In agreement with this approach, our SPR imaging prism was considered to consist of N -layers. Therefore, to obtain the reflectivity in this multi-layer system, the transfer matrix method was considered. This formalism was first established in 1950 by Abeles,¹⁸ which was further expanded in 1968 by Hansen.¹⁹ The transfer matrix approach highlighted by Hansen was closely followed in this study (see Supporting Information).

The significance of this approach lies in its simplicity to accurately and precisely determine the reflectivity with the absence of approximations. Each layer of the model is considered to be stacked on the z -direction defined as a function of its complex relative permittivity ϵ_N (square of its optical index n), its complex relative permeability μ_N and its thickness d_N . The summarized idea of this multi-layer matrix method is schematically represented in figure 1. Nevertheless, the drawback of this method arises from the assumption that these layers are considered to be homogeneous, isotropic and plane-bounded. Thus, the roughness of the successive layers is not taken into account.

Figure 1: Schematic representation of the multi-layer system used for the calculation of the reflectivity. Incident light, with a specific wavelength (λ), is considered with transmission losses through the prism (layer 1) quantified by the transmission function T .²⁰ For its definition the external incident angle (θ_{ex}), prism optical index (n_1) and the Apex angle of the prism (θ_{Ap}) are used. For the transfer matrix method, the adhesive layer (layer 2) and Au layer (layer 3) are followed with successive layers defined by their complex relative permittivities ϵ_N (square of their optical index n), complex relative permeabilities μ_N and their thicknesses d_N which is utilized with the internal incident angle (θ_{in}) experimentally equivalent to the working angle (θ_w). These parameters and there relationships are further explained in the supplementary section.

In accordance, we initially considered a 4-layer system ($N = 4$). Since only non-magnetic

materials are present in the model, μ_N is equal to 1 for all the relevant layers. Furthermore, the glass prism made of NBK-7 (layer 1) and the Dry Air carrier gas region (layer 4) are considered to be semi-infinite along the z -axis on opposite directions. The Au layer (layer 3) is generally attached to the prism through a thin metallic layer of Cr or Ti (layer 2) for better adhesion purposes. For all the other layers, except for the thin adhesive layer (due to its low thickness), the effect of temperature was considered when driving its complex relative permittivity ϵ_N . To ensure the robustness of the models employed, fitted models were chosen from experimental observations at ambient conditions²¹ and varied temperature studies.^{22–24} In addition, the effect of pressure was introduced into the permittivity function of the gas phase (layer 4) for the theoretical analysis of the system’s performance. Table 1 summarizes the 4 layers incorporated into the basic matrix model for the reflectivity. The models used for the permittivity functions of each layer are listed, referencing the experimental studies from which they are derived. The optimum d_N values, for increased sensitivity, were chosen based on previous studies showing an adhesive layer thickness of $\approx 2\text{ nm}$ and an Au layer thickness of $\approx 53\text{ nm}$.^{25,26} However, the real obtainable thicknesses, with slight over shot from set values, were experimentally obtained using a Quartz Crystal Microbalance (QCM) in each case.

Table 1: Summary of the information on the layers in the simulated multi-layer system.

N	Material	d_N [nm]	Model
1	NBK-7	∞	Temperature-dependent Sellmeier equation based model ²²
2	Cr/Ti	$d_2 = [0 - 6]^*$	Brendel-Bormann model ²¹
3	Au	$d_3 = 54.5^*$	Temperature-dependent Drude-Sommerfeld model ²³
4	Dry air	∞	Temperature & Pressure-dependent Sellmeier equation based model ²⁴

* Obtained experimentally from QCM measurements during the physical vapor deposition procedure for a set of optimized thickness ($d_2 = 2\text{ nm}$, $d_3 = 53\text{ nm}$).

Surface topography layer

An important limitation for the matrix model involves the incorporation of the surface topography damping effects. There are only a few studies which have dealt with simulating the effects of surface topography on the SPR phenomenon.^{27–29} In each of the cases, different approaches were explored. In this work we will be focusing on the approach known as the modified Maxwell-Garnet Theory (mMGT). Taking into account the use of a multi-layer system, the main advantage of mMGT is its specific applicability within the transfer matrix method. In fact, mMGT treats the surface topography as an additional layer within the model. The dielectric function of this effective layer (ϵ_{eff}) was defined in mMGT by relating the dielectric function of the host media (ϵ_4) with the dielectric function (ϵ_3), volume fraction (f) and depolarization factor (v_p) of the metal inclusions. Equation 1 relates the effective permittivity of the roughness layer with the modified Maxwell-Garnett mixing formula from the permittivities of the pure phases and accounting for the geometry of the metal inclusions.³⁰

$$\epsilon_{eff} = \epsilon_4 \Delta \frac{\epsilon_4 + [v_p(1 - f) + f](\epsilon_3 - \epsilon_4)}{\epsilon_4 + v_p(1 - f)(\epsilon_3 - \epsilon_4)} \quad p = x, y, z. \quad (1)$$

Due to large variations in metal inclusions when considering topography, a conjecture was made that the mixing formula (Eq. 1) was a valid approximation, as long as, on average, the medium was spatially uniform and anisotropic.³⁰ The depolarization factor ($0 < v_p < 1$) acts as a measure representing the weakening of the internal field due to polarization damping, while also providing an indication of the geometry of the forenamed metal inclusions. The individual depolarization factor coefficients along the three directions follow the normalization condition $v_x + v_y + v_z = 1$. To further understand this approximation, we need to assume similarly oriented ellipsoids with semi-axes a_x, a_y, a_z parallel to the Cartesian axes (see figure 1 and figure 5). In the case of prolate ellipsoids, $a_x = a_y \ll a_z$ (geometrically equivalent to thin needle shapes) depolarization factors correspond to $v_x \simeq v_y \rightarrow 1/2$ and $v_z \rightarrow 0$. Whereas, for

oblate ellipsoids, $a_x = a_y \gg a_z$ (geometrically equivalent to flat pancake shapes) $v_z \rightarrow 1$ and $v_x \simeq v_y \rightarrow 0$. General expressions for these geometrically dependent depolarization factors are given by $v_x = Q(a_x, a_y, a_z)$, $v_y = Q(a_y, a_z, a_x)$ and $v_z = Q(a_z, a_x, a_y)$. For the purpose of this study, v_z is the only depolarization factor considered, in accordance with the transfer matrix method, as it has most significant contribution to the prism sensitivity. In addition, the most pertinent effect derived from the experimental data is the polarization damping in the z -direction of the prism. The following equations were derived for oblate ellipsoids, following the condition of $a_x = a_y > a_z$.³¹

$$Q(a_z, a_x, a_y) = \frac{a_x a_y}{2a_z^2} \int_0^\infty H(s, a_z, a_x, a_y)^{-1/2} ds \quad (2)$$

with

$$H(s, a_z, a_x, a_y) = (s + 1)^3 \left(s + \left(\frac{a_x}{a_z}\right)^2\right) \left(s + \left(\frac{a_y}{a_z}\right)^2\right)$$

Experimental considerations

Gas phase SPR imaging setup

The custom-built gas phase SPR imaging system under consideration follows the intensity interrogation approach. Here, the refractive index variations of the gas phase are detected on the basis of a change in the reflectivity at a fixed wavelength and incident angle.³² Following this approach, initially, the most suitable operating angle was identified manually with angular scans. Once identified, this working angle (θ_w) was fixed and the reflectivity $R(t)$ of the region of interest (ROI) was monitored as a function of time. θ_w was usually selected to give the highest slope of the linear region of the plasmon curve, thereby selected close to the angle maximizing $\partial R / \partial \theta$. However, the system only allows for incremental angular shifts of 0.25° , therefore, the closest possible angle within this range was selected. This angular interrogation was performed for every sample being analyzed to ensure maximum achievable

sensitivity of the system, enabling better characterization of small refractive index changes.

This custom-built setup, schematically represented in figure 2, was equipped with a 625 nm intensity modulated Light Emitting Diode (LED) (M625F2, Thorlabs). However, since 632.8 nm wavelength was used for VOC analysis,⁷ a bandpass filter (central wavelength 632.8 nm, bandwidth 3 nm - FL05632.8-3, Thorlabs) was employed right after the prism to capture the relevant wavelength of reflected light. In relation to the intensity losses induced during transmission through the filter, the power modulator unit (KPS101, Thorlabs) ensured due compensation for these losses. Initially, the beam from the optical fiber was evenly distributed using a diffuser as a means of preventing hot-spots. Then the beam was collimated, to ensure the required ROI was entirely illuminated. Following which the beam was passed through a linear polarizer (extinction ratio > 1000 : 1 - LPVISE100-A, Thorlabs) in order to achieve the Transverse Magnetic/Electric (TM/TE) modes required for SPR sensing. Once the beam was reflected off the metal coated prism surface, it is passed through the filter before being finally captured by a 16-bit CCD camera (AVT PIKE F-145B, Allied Vision Technologies), with a resolution of 1388×1038 pixels. The captured image of the ROI is then constantly monitored at the TM mode. This entire optical setup was placed under a temperature controlled environment (Mettler Oven). The reflectivity of the system was calculated and monitored using a data acquisition and analysis program designed using LabVIEW (National Instruments).

In addition to this optical setup, a fluidic system was employed for controlled gas phase analyses. It was crucial in this study that the pressure and flow were accurately controlled throughout the system. Therefore, a simple fluidic setup was implemented with a mass-flow controller and a pressure controller (Bronkhorst, Netherlands). The flow was set to 100 ml/min and a baseline pressure was set 50 mbar above ambient conditions (absolute pressure of 1063.25 mbar) to ensure carrier gas flow through the head space. Four different carrier gases were analyzed in this study, namely, Ar (purity 99.99%), CO₂ (purity 99.99%), He (purity 99.99%) and Dry Air (< 1 ppm of CO₂+CO, < 0.2 ppm of tertiary hydrocarbons).

Figure 2: Schematic representation of the custom-built experimental setup. A 625 nm LED is coupled to an optical fiber, followed by a diffuser, at the point source, through which the light is scattered. The initial lens collimates the beam which is then *s*- or *p*-polarized (TE and TM modes) via the linear polarizer. The working angle (θ_w) representing the incident beam perpendicular to metalized surface is calibrated, however, limited by 0.25° increments. The Flow cell is used to create a pressure lock over the illuminated ROI. The subsequent bandpass filter narrows the spectral distribution to obtain the required working wavelength of 632.8 nm. Followed by the focusing lenses before the image is captured using a 16-bit CCD camera. In addition, the fluidic setup placed outside the temperature controlled environment consists of a pressure and mass flow controller with gas flow and system pressure modulation capabilities.

and $< 3 \text{ ppm}$ of H_2O). The pressure of these carrier gases were modulated accurately using a control loop feedback mechanism, where the evacuated gas was conserved using a hand operated gate valve.

Metal film deposition on prisms

Metal film deposition on the active prism surface was performed using an electron (e-) beam evaporator, Plassys MEB 550-S, in a clean-room environment. This physical vapor deposition (PVD) technique was selected for a plethora of advantages pertaining to optical thin film applications.³³ However, in relevance to our study, this method was best suited due to its ambient operating temperatures. In accordance, the sample prisms were kept at low temperatures during Au-film deposition, preventing formation of isolated Au islands prevalent with samples exposed to high temperatures.³⁴ In addition, multi-crucible e-beam sources provided the capability to sequentially evaporate metals, preserving the vacuum. This was another unique advantage, as it prevented contamination during the design of multi-layer systems similar to our own. In addition to these immediate benefits, it was also important to consider the future miniaturization and mass production of such gas phase SPR imaging sensor prisms. Thus, e-beam evaporators provided faster deposition rates enabling high efficiencies and low cost production lines.³⁵

For the preparation of high RI sample prisms, initially, 25 mm right apex angled ($\theta_{Ap} = 90^\circ$), NBK-7 prisms (Edmund optics) were etched with an Ar^+ ion gun at 250 V for 24 s (optimized parameters). This process ensured a clean and considerably flatter surface prior metal deposition (see figure S3). After this etching process the required metal thin film layers were deposited, inline with our setup corresponding to the Kretschmann configuration. The accuracy of the deposition rate and film thickness were determined by QCM, where the reproducibility of the layer thickness was $\pm 1 \text{ s}$ of the deposition rate.

For this work, three different samples were prepared to analyze the effect of adhesive layers (Cr or Ti) on the surface topography of the thin film Au-layer, with the subsequent

translation of these topography effects onto the sensitivity of these SPR imaging sensor prisms. A summary of the prepared samples are shown in table 2.

Table 2: Summary of sample prisms prepared using Plassys MEB 550, e-beam evaporator.

Sample	Deposition Layers	Deposition rates [nm/s]	Layer Thickness [nm]
1	Cr/Au	0.1/0.25	2.4/54.5
2	Ti/Au	0.1/0.25	3.6/54.5
3	Au (no adhesive layer)	0.25	54.5

AFM analyses

For Au surface characterization of the samples shown in table 2, AFM scans were performed using the Dimension FastscanTM (Bruker). However, for the visualization of the initial and intermediate stages of the SPR imaging prism preparation, a more commonly used Dimension IconTM (Bruker) was used. With the FastscanTM, surface topography data were acquired in tapping mode under ambient conditions. A higher resolution Si_3N_4 cantilever having an integral tip with spring constant of 17 N/m and tip diameter of 5 nm was used (FASTSCAN-A, Bruker). Images were obtained by oscillating the cantilever slightly below its resonance frequency (1400 kHz) and raster scanning across the surface. With the IconTM, a lower resolution Si_3N_4 cantilever having an integral tip with spring constant 0.4 N/m and tip diameter of 5 nm was used (SCANASYST-AIR, Bruker). Images in this case were obtained by ScanAsyst[®] mode a type of peak force tapping mode[®].

A $1 \times 1\mu m^2$ area was scanned for each sample at the center of the ROI. The images obtained for each of the samples had a resolution of 512×512 , which were quantified using Gwyddion software. The images were leveled and filtered. Further analyses were performed using the Gwyddion built-in algorithms and then the data were fitted and graphically represented (with an interpolation function of order 3) using the Mathematica computational platform. Note that all the AFM images were plotted at scale - $1 \times 1 \times 0.4$, to better highlight the surface topography. The same scaling was maintained for comparative analyses

with different color gradients to emphasize the material being represented (see figure S3).

Results and discussion

Prism sensitivity characterization

In order to analyze and compare performances of different SPR imaging prisms, it was imperative to establish a standardized method to characterize the prism samples independent of the measurement procedure. A sensitivity measure, which is prevalent in literature^{25,36} is defined as the reflectivity variation per refractive index unit (RIU) or $\partial R/\partial n$. The utilization of a gas phase SPR imaging system gives us the unique advantage of using pressure as a physical parameter affecting the refractive index of the gas. This dependence was capitalized upon to obtain $\partial R/\partial P$, experimentally from pressure jumps, with various gases. The derivation of the SPR imaging system performance, $\partial R/\partial n$, is then deduced from the calculated values of $\partial P/\partial n$ for the various gases considered following this simple relation:

$$\frac{\partial R}{\partial n} = \frac{\partial P}{\partial n} \times \frac{\partial R}{\partial P} \quad (3)$$

To experimentally validate the proposed pressure based sensitivity factor approach, 4 different carrier gases were tested (Ar, CO₂, He and Dry Air) with the current Cr/Au (prism sample 1) configuration used in our opto-eN system. Three pure gases were chosen with the Dry Air mixture to emphasis the robustness of this approach. The experimental approach involved monitoring the change in reflectivity over time at a fixed working angle (close to the one maximizing $\partial R/\partial \theta$) and at a constant working temperature of 25°C. Then, to obtain $\partial R/\partial P$ the pressure was increased, sequentially, from 50 *mbar* (above ambient pressure) up to 450 *mbar* at 100 *mbar* increments. These step-wise pressure jumps were repeated, immediately, in the opposite direction (as shown by the temporal response of the system for Dry Air in the inset of figure 3) to account for any baseline drift in the SPR imaging

signal. The pressure was maintained at each increment for two minutes following which the signal plateaus, at each pressure point, were averaged to obtain the change in reflectivity with respect to pressure (as shown in figure 3). A strong linear relationship was observed, through which the experimental $\partial R/\partial P$ values were extracted. Five spots (replicates) with diameters of $200\ \mu\text{m}$ were chosen and analyzed to accurately represent the entire ROI of the prisms. In addition, the experiments were also repeated twice to ensure the reproducibility and accuracy of the experimentally derived data. In effect, the standard deviation values for $\partial R/\partial n$ accounts for both the replicates and experimental repeats.

Figure 3: Experimental change in reflectivity (ΔR) with respect to pressure for the 4 different gases (CO_2 , Dry Air, Ar and He). A linear fit was obtained. **Inset** - The temporal response of reflectivity for a single repeat pressure scan, showing the 100 mbar pressure increments with Dry Air (visualization of raw data).

As seen in table 3, pure gases/gas mixtures with larger molecular weights had a larger $\partial R/\partial P$. Therefore, in order to determine an independent measurement of the SPR imaging set-up performance, it was important to obtain $\partial R/\partial n$ which is independent of the carrier

gas being used. The next step along this line was to obtain $\partial n/\partial P$ values. The effect of pressure on the refractive index of pure gases have been well documented. The Hauf-Grigull relation ³⁷ (equation 4) was used to calculate these values for the 3 simple carrier gases, Ar, CO₂ and He:

$$n(\rho) - 1 = \frac{3}{2} \frac{rMP}{RT} \quad (4)$$

where r is the gas refractivity, M is the gas molar mass, P is the pressure, R is the ideal gas constant, and T is the temperature which was set to ambient (25°C) in our case .³⁸ For Dry Air, however, the effect of pressure on its refractive index was a more complex relationship. Since Dry Air was a mixture of gases, it was important to introduce additional parameters, such as humidity and CO₂ concentration, to improve the accuracy of the $\partial n/\partial P$ values that needed to be extracted. A robust experimentally verified model proposed by Ciddor ²⁴ was used for this purpose, where pressure, humidity, CO₂ concentration, temperature (and its effects on the saturation vapor pressure) were related to the refractive index change of Air. In the Supplementary Information we present the refractive index variations of the 4 different carrier gases with respect to changes in pressure (figure S1).³⁸ The parameter $\partial n/\partial P$ were extracted via a linear fit.

Interestingly, we can observe in table 3 that the experimental values for $\partial R/\partial P$ are highly sensitive to the carrier gases utilized. However, when corrected using the pressure dependence on the refractive index ($\partial P/\partial n$) the overlap of the sensitivity parameter $\partial R/\partial n$ is excellent and lies within error bars for all 4 carrier gases. This validates the use of $\partial R/\partial n$ as a sensitivity parameter for the set-ups performance and allows us to compare performances between various prism samples independent of the carrier gas being used.

The sensitivity of Cr/Au prism (sample 1) was considered to be $\partial R/\partial n = 6650 \pm 60 \text{ \%}/RIU$, for the default carrier gas, Dry Air. Based on such a performance, we can further analyze the LOD of the SPR imaging system. For this purpose, the noise fluctuations of the reflectivity signal were identified to be approximately 0.05% (see figure S2). From the minimal signal detectable, corresponding to the level of noise, the minimum resolvable bulk

Table 3: Values obtained for the sensitivity parameter using prism sample 1 with Cr/Au layers. All experiments were carried out at ambient temperature ($25^{\circ}C$).

Carrier Gas	$\partial R/\partial P$ [%/mbar]	$\partial n/\partial P$ [RIU/mbar]	$\partial R/\partial n$ [%/RIU]
Carbon dioxide (CO_2)	4.21×10^{-7}	0.00279	6640 ± 30
Dry Air	2.55×10^{-7}	0.00169 [*]	6650 ± 60
Argon (Ar)	2.51×10^{-7}	0.00166	6620 ± 30
Helium (He)	3.13×10^{-8}	0.00021	6640 ± 80

($CO_2 = 1\text{ ppm}$)

refractive index change for the Cr/Au prism is about 7.5×10^{-6} RIU, which is comparable to the LOD of many reported affinity based SPR imaging biosensors in liquid.¹ The relevance of this bulk carrier gas LOD is tied with real world VOC measurements as the carrier gas (Air) composition changes situationally, especially during *on-field* detection. For instance, a 10% increase of relative humidity in air leads to an approximate change of 10^{-5} RIU.²⁴ Thus, 1% change in humidity could ideally be detected by the SPR imaging set-up and potentially be compensated for. Such correction of external parameters like humidity or temperature would improve the VOC signature leading to more robust and reproducible measurements in varied environmental conditions. Thus, this sensitivity factor approach would be the ideal means to calibrate such SPR imaging prisms before their utilization. And furthermore could be also an important characterization tool for the immobilized receptors on the sensing array.

Similarly, $\partial R/\partial n$ was experimentally extracted for the Ti/Au prism sample 2, giving a value of 6490 ± 120 %/RIU at a similar maximized working angle. The standard deviation for sample 2 was twice that of sample 1, which was a result of the significant variability in experimental replicates. The minimum distinguishable reflectivity (noise) which was about 0.07% was slightly higher than that of sample 1, leading to a minimal resolvable bulk refractive index change of 10^{-5} RIU. Moreover, the pressure jump experiments were also performed on prism sample 3 with only a Au layer. However, with no adhesive layer (either Ti or Cr), there was a large signal drift and noise observed (shown in figure S2). As a result, it was not possible to obtain reliable $\partial R/\partial n$ values.

It was clear from this initial experimental study that adhesive layers played a vital role in obtaining reliable and reproducible results. Furthermore, Cr/Au prism sample 1 was identified as the better sensor prism at $25^{\circ}C$ and working angle $\theta_w = 42.5^{\circ}$, as it showed higher sensitivities with better reproducibility of performances due to smaller standard deviation values. The comparison between Ti or Cr adhesive layers on the performance of the SPR imaging set-up is analyzed in more detail and compared to model predictions in the following sections.

Theoretical comparison of Cr and Ti adhesive layers on prism sensitivity

As previously discussed, it is well known that PVD of Au directly onto a glass substrate suffers from weak adherence of the layer due to the low reactivity of similar noble metals. To enhance this adherence usually an adhesive layer ($1 - 6\text{ nm}$) of Cr, Ti or their oxide forms are used.³⁹ Over the years, significant strides have been made to understand the effects of adhesive layers on the SPR phenomenon. Recent studies have shown that Ti was preferred over Cr as it absorbed light less strongly and was prone to less variations in transmission⁴⁰ (which can be seen in figure 4 - Inset). In addition, comparative studies have shown a localized surface plasmon damping in plasmonic nanostructures due to the presence of a very thin adhesive layer. Overall better performances were noticed for Ti over Cr for the nano-optic applications.^{41,42}

To understand this further, the initial 4-layer model was used. In retrospect, it is important to understand that when performing PVD metal depositions, generally, there is an overshoot from the set film thickness. This is usually attributed to the vaporized metal remaining in the deposition chamber. As a consequence, at similar deposition rates, Ti generated a thicker layer compared to Cr for an optimized set thickness value of 2 nm (shown in table 2). The vapor pressure of Ti was higher than that of Cr,⁴³ making it more volatile, resulting in a larger amount of metal vapor remaining in the deposition chamber. The de-

pendence of this adhesive layer thickness d_2 on the sensitivity parameter $\partial R/\partial n$ is shown in figure 4. Where, it can be inferred that by decreasing d_2 the sensitivity could be further improved. The rational behind this result is linked to the dielectric permittivities of the metals. For surface plasmon propagation, at certain resonance conditions, the real and imaginary part of the permittivities govern the significance of the plasmonic effect. The real part directly corresponds to the resonance condition whereas the imaginary part corresponds to the internal damping of the transmitted power. Cr and Ti have a considerably larger imaginary part which broadens the spectral width of the plasmon curve at all given wavelengths. Therefore, essentially, to maximise sensitivity a pure Au layer (with the largest plasmonic effect) with no adhesive layer would be ideal. This is validated in figure 4, where a maximum value of $\approx 9500 \%/RIU$ was theoretically predicted for both samples in the simulated model with no adhesive layer. However, as seen earlier with prism sample 3, direct Au deposition onto a NBK-7 prism provided experimentally unreliable results, due to large signal drift and noise. This was expected, as the fluctuations in the signal were related to the gradual detachment of Au from the NBK-7 prism. Evidence of this weak adherence was physically noticeable in sample 3, which showed heavy signs of delamination and peeling, progressively worsening with an additional time-dependent performance deterioration. In essence, a thickness of $d_2 \simeq 2 \text{ nm}$ for the anchoring layer (either Cr or Ti) was a good compromise between the complete NBK-7 surface coverage and optimized sensor prism performance.

$\partial R/\partial n$ for Cr and Ti based prisms were theoretically determined to be $8170 \%/RIU$ and $8350 \%/RIU$, respectively, after adhesive layers thickness were set (see Figure 4). This was in agreement with previous studies, as it showed a performance enhancement with the use of Ti as an adhesive layer. However, experimental performances $\partial R/\partial n$ showed much lower sensitivity values at a similarly optimized working angle $\theta_w \simeq \theta_{max}$ where θ_{max} corresponds to the angle maximizing the performance $\partial R/\partial n$. These sensitivity losses, attributed to surface topography damping effects, are experimentally validated in the following section.

Figure 4: Theoretical $\partial R/\partial n$ for both Cr (Red) and Ti (Blue) with respect to the thickness of each adhesive layer. Results obtained via the initial 4-layer model; the model was established with Au thickness generated from the deposition (54.5 nm) and at an optimized set working angle of 42.5° for maximized sensitivity. **Inset(s)** - Reflectivity (%) with respect to the angle (θ) for both Cr (bottom) and Ti (top) at adhesive layer thicknesses 0, 2, 4, and 6 nm .

Impact of Surface topography on prism sensitivity

As seen earlier, when experimentally verified, the sensitivities for Cr and Ti adhesive layer prisms were found to be 6650%/RIU and 6490%/RIU, respectively. These values are significantly lower than the predicted sensitivities for the initial model with the 4-layer system. This system assumes a homogeneous, flat surface. Therefore, it fails to account for any surface topography damping effects that might affect the performance of the system. It is important to characterize these losses as they accounted for an approximate 20% of reduction in the systems estimated performance. Which, when fully understood, could be further used to enhance our opto-eN system to achieve lower LOD. In order to consider these losses an additional 5th layer, known as the effective layer, was introduced into our theoretical model. This 5th layer was governed by the mMGT. As seen earlier, the mMGT is a mixture model which characterizes the surface topography as a collection of ellipsoidal inclusions on the surface of layer 3 (scheme in figure 5). To correctly implement the dielectric function of this effective layer, it is necessary to first derive two parameters v_z and f , experimentally. For this purpose, $1 \times 1 \mu m$ AFM measurements were taken at the center of the ROI for each of the samples (shown in figure 6). In validation of our choices and constraints of the mixing model, randomly distributed regular grains (semi-ellipsoidal in shape) were noticed on the surface of these adhesive layer based samples (1 and 2). This was coherent with another Ti/Cr based adhesive layer study, as they were shown to enhance surface wetting leading to more nucleated grain growth with a narrow grain size distributions^{.42} However, for sample 3, the scans showed no such regularity in grain size or shape which further validated this idea, correlating to its weak adherence. To ensure that the presence or absence of these grains were purely a result of the adhesive layers, AFM measurements were taken along all the intermediate sample preparation steps (before and after etching, and after adhesive layer deposition) (shown in figure S3). It is clear that these semi-ellipsoidal grains can only be seen on the Au surface as a result of the presence of these adhesive layers. The etching seems to play an important role in flattening the surfaces of these NBK-7 prisms,

as predicted, since the Root-Mean-Squared roughness (R_q) was decreased from 1.06 nm to 0.60 nm after etching. Following which, the flatness is shown to be maintained with the adhesive thin film deposition. With even a slight improvement, represented with a small decrease in the R_q (0.50 nm for Cr and 0.45 nm for Ti adhesive layers). However, after the deposition of Au, the R_q was seen to increase, drastically, to 1.8 nm and 1.5 nm for sample 1 and 2, respectively. In accordance, this increase in roughness was primarily visualized as these aforementioned regular, semi- ellipsoidal grains. For sample 3, R_q was calculated to be 1.3 nm which, visually, didn't have a well defined shape or regularity.

Figure 5: Schematic representation of the application of the mMGT - Au grains are represented as ellipsoidal inclusions (with semi-axes a_x , a_y and a_z parallel to the Cartesian axes) in a Dry Air host media forming our effective layer. The modified layer thicknesses are shown in the 2D cross-section of the ROI.

Now, before implementing this new 5-layer system a few considerations need to be made to the initial model. When using the mMGT, grains are visualized to be similarly oriented ellipsoidal inclusions with semi-axes a_x , a_y and a_z parallel to the Cartesian axes. Knowing this, d_3 needs to be modified by subtracting a_z as the QCM measurements only account for the mean value of the deposited height of the Au layer. Following which, the thickness of the effective layer d_{eff} is also represented with $2a_z$ gauging its complete shape (shown in

figure 5). Moreover, since the surface topography was considered as an additional layer in the model, the resultant resonance angular shift were compensated for. Furthermore, the additional layer also elongated the plasmon curves corresponding to the internal damping predicted by the model, thus the experimental intensities were also adjusted accordingly. This stays inline with the idea that both these layers are in fact just a single layer exhibiting different plasmonic behaviors reflecting realistic experimental conditions. Following these considerations, for the implementation of the mMGT, 4 new parameters were needed. These included the indicative average dimensions of these ellipsoidal inclusion (a_x , a_y and a_z) and the estimated volume fraction f of these said inclusions.

Firstly, a_z was considered. a_z plays a significant part in the derivation of v_z and d_{eff} . To find its best representative value, a distribution was constructed from the z -axis heights obtained via the AFM surface profiles. The distribution was seen to fit best with a Gaussian function G (equation 5), showing that it was isotropic, corresponding to a certain level of z -direction regularity in grain structure. G was fitted with A the amplitude and σ the standard deviation of the distribution. a_z was determined as 3σ which accounted for $\approx 99.7\%$ of the distribution (see figure S4). Which meant that most of the noise observed in the tails of the Gaussian ($z > 3\sigma$) and related to measurement technique were ignored, giving a more representative value. This is especially important with Cr adhesive layer where the trailing ends of the Log-Height distribution were ignored (figure S4 Inset). These trailing ends were related to higher levels of impurities and surface defects seen on this particular sample.

$$G(z) = A\Delta e^{-\frac{z^2}{2\sigma^2}} \quad (5)$$

a_z was calculated for Cr and Ti samples yielding values of 5.4 nm and 4.7 nm , respectively. σ , in our case, also closely related to the R_q of the system since our mean height was set to zero.⁴⁴ This approach is significant, similar to previous works,²⁸ as it also provides a roughness characterization parameter.

Secondly, in contrast to these previous roughness studies, two other geometric contribu-

Figure 6: Left: AFM analyses for the 3 samples; a) Cr/Au prism sample 1, b) Ti/Au prism sample 2 and c) No adhesive layer, pure Au surface, prism sample 3. Note that the axes are not to scale. Right: The 2D FFT plots for the estimation of the average lateral grain dimensions.

tions (a_x and a_y) are vital in the estimation of v_z . Though their effects are nominal, they still provide extra information in characterizing these effective layers more accurately and robustly. For this purpose a technique known as the 2D Fast Fourier Transform (2D-FFT) was performed on the AFM data. Figure 6 (right) shows the 2D FFT plots, generated by Gwyddion, for the AFM images of the 3 samples. These plots represent the z -axis height correlation intensities in the reciprocal space of the lateral dimensions. The 2D-FFT data provide a unique advantage, as they can be used to obtain the average lateral dimensions of any regular structures when fitted. A Lorentzian fit (Equation 6) seemed to best represent these grains (shown in figure S5). As an additional validation of this approach, similar 2D Lorentzian fits were used in AFM simulators for nanodot oxide growth on silicon substrates,⁴⁵ which showed similar semi-ellipsoidal shapes as seen on our Au surfaces.

$$L(x, y) = \frac{A}{1 + (a_x x)^2 + (a_y y)^2}. \quad (6)$$

For sample 3, instead of grains, wrinkles were seen to be randomly propagating along the surface. These surface topographies seem to be the result of this weak magneto-plasmonic adherence causing the unviability of this sample for the use in SPR imaging. Neither of the fits seemed to work with this 2D-FFT data. In addition, sample 3, was also shown to have an uneven surface. This was attributed to the lower surface wettability of NBK-7, forming fewer nucleation sites leading to uneven grain growth before coalescence. This meant that the use of these adhesive metal layers not only helped in Au adherence but also created a more uniform deposition, giving a lower positional variability of its sensitivity on the prism surface.

For sample 1 and 2, the grains are clearly more prominent. An increased number of nucleation sites decreases the energy barrier for the formation of densely packed grains with a narrow grain size distribution, which seemed to differ with respect to the adhesive layer used. a_x and a_y values for Cr prism sample 1 were estimated to be 30.8 nm and 29.3 nm while for Ti prism sample 2 were estimated to be 29.3 nm and 27.5 nm , respectively, from

the Lorentzian fits (Equation 6). The values of a_x and a_y were approximately equal and showed to be at least 3 times larger than a_z , which satisfied the oblate ellipsoidal condition of the mMGT model ($a_x \approx a_y > a_z$).

Finally, the volume fraction f was estimated for samples 1 and 2. For this purpose, initially, the granular volume was calculated of the filtered AFM image (noise and defects removed) using the built-in Gwyddion functions. This was done by first masking the image with a height threshold (a_z), obtained previously. The relative volume fraction was then extracted by dividing the calculated grain volumes from the dimensions of our effective layers ($d_{eff} \times 1 \mu m \times 1 \mu m$). f was calculated to be 0.46 and 0.52 for samples 1 and 2, respectively. These values were concurrent with what was expected, as sample 2 had slightly more oblate grains within a smaller effective layer. Moreover, even though f has a strong dependence on a_x , a_y and a_z , surface coverage of these ellipsoidal grains (essentially directly correlated to the number of nucleation sites) also need to be considered when characterizing this f . To further, numerically, understand the surface coverage of these grains an automated Otsu's thresholding method was applied on the AFM images (as seen in figure S6). Even though a slight decrease in surface coverage was seen for sample 1, the relative projected area of the grains was $\approx 51\%$; almost similar for both sample. Therefore, in our case it can be concluded that the largest contributor to the variation in f is the grain geometry in relation to the effective layer size rather than the grain packing density.

Since all the parameters required for the mMGT were experimentally obtained, the new 5-layer system was used without adjustable parameters to extract the theoretical prism sensitivities. Initially, plasmon curves were obtained at a temperature of $25^\circ C$ as a function of the incident angle (see figure 7). While the model without and effective layer presented deviations from the experimental results for both Cr and Ti adhesive layer samples, the mMGT with an effective layer and no adjustable parameters showed strong agreement with the experimental data in the full range accessible for both samples. Moreover, theoretical $\partial R/\partial n$ values of $6570\%/RIU$ and $6560\%/RIU$ calculated for Cr/Au and Ti/Au prism

Figure 7: Plasmon curve: Reflectivity (%) changes with respect to the incident angle (θ). The experimental points (at 0.25° increments) are compared with the 2 models with and without effective layer. The model with the inclusion of the surface topography consideration via experimentally derived mMGT shows a stronger agreement with experimental data compared to the model with no effective layer. In both cases, no adjustable parameters were required. The working angle (θ_w) for both samples was experimentally set to 42.5° for further analyses. Note that the error bars were within the dot size.

samples, respectively, matched with the experimentally observable values of $6650 \pm 60 \text{ \%}/RIU$ and $6490 \pm 120 \text{ \%}/RIU$ (obtained at 42.5° as shown in figure 7). The sensitivity losses were captured well with a high degree of accuracy validating our approach for surface topography consideration and their damping effects. In an effort to round off the adhesive layer study, the impact of these surface topographies were included in the re-evaluation of the effect of adhesive layer thicknesses on the prism sensitivities. Figure S7 represents this sensitivities at the achievable working angle θ_w of 42.5° for both Cr and Ti metals. As seen in the Figure S7, with the experimental layer thicknesses ($d_2 = 2.4 \text{ nm}$ for Cr and $d_2 = 3.6 \text{ nm}$ for Ti), both theoretical sensitivities are similar reinforcing the validity of the experimental results which showed comparable Cr/Au and Ti/Au prism performances. The intersection of the two curves falls close to the optimized adhesive layer thickness of 2 nm suggesting that either Cr or Ti metals would be convenient. Above this optimal thickness of 2 nm , the adhesive layer with Ti presents improved sensitivity compared to Cr. Table 4 summarizes the experimental values for surface topography characterization, the working angle θ_w , the angle θ_{max} (theoretically maximizing the sensitivity) and finally the comparison between experimental and theoretically derived prism sensitivities at $25^\circ C$.

Table 4: Experimentally extracted values f , a_x , a_y , and a_z from AFM measurements. Working angle θ_w and the angle θ_{max} theoretically maximizing the sensitivity. Finally, the theoretical (mMGT) and experimental sensitivities $\partial R/\partial n$ of SPR imaging prisms. Values obtained and modeled at $25^\circ C$.

Sample	f	a_x	a_y	a_z	θ_w	θ_{max}	Theory	Experiment
Units		[nm]	[nm]	[nm]	[$^\circ$]	[$^\circ$]	[%/RIU]	[%/RIU]
1-Cr/Au	0.46	30.8	29.3	5.4	42.5	42.43	6570	6650 ± 60
2-Ti/Au	0.52	29.3	27.5	4.7	42.5	42.39	6560	6490 ± 120

Based on this model, the impact of surface topography on prism sensitivity is governed by three parameter; $a_{x,y}$, a_z and f , which represent the grain geometry, volume and distribution. To better understand their individual impacts, the maximized $\partial R/\partial n$ (at $\theta_w = \theta_{max}$) were obtained by constraining the other parameters close to their experimental derived counterparts ($a_{x,y}$, a_z and f were constrained to 5 nm , 30 nm and 0.5 , respectively).

$\partial R/\partial n$ were then extracted with respect to these individual parameters. For the parameter a_z (figure S8a), the performance showed a significantly higher impact compared to the lateral geometry $a_{x,y}$ parameter (figure S8b). It is clear that the prism sensitivities could be improved significantly with flatter oblate ellipsoids ($v_z \rightarrow 1$ or $a_z/a_{x,y} \rightarrow 0$). In contrast, as the effective layer thickness gets smaller, with increasingly oblate spheroids, f being a relative volume fraction, would increase. This would be counter productive, as an increase in f showed to create a decrease in the sensitivity $\partial R/\partial n$ (figure S8c). Meaning that less densely packed grains (smaller surface coverage) should help in achieving higher sensitivities in this case, as it would also mean less grain boundaries leading to lower damping effects.

Moreover, sample 2 gave high variability in its sensitivity measurements coupled with a slightly higher noise and signal drift (which can be seen in figure S2). This, however, was not attributed to the grains. It is more likely that this variability is due to the relatively weaker adherence between Ti and Au compared to Cr. The high tendency for Cr to form an oxide leads to a stronger Cr-O chemical bond. Such bond strengths increase its adhesive properties in contrast to Ti. Furthermore, the higher diffusivity of Cr compared to Ti leads to Cr-Au inter-diffusion. Here, the number of Cr-Au bonds could be speculated to exceed the number of Ti-Au bonds, where the chemical bonding could only happen at the surface interface.⁴² Accordingly, even though slightly higher sensitivities could be theoretically achieved using Ti/Au prism 2 (at θ_{max}), Cr/Au prism samples prove to be the better choice. As they show lower adhesive layer thickness over-shots during prism preparation and lower sensitivity variabilities, noise and signal drift during utilisation. This make them the better option for opto-eN applications, providing better, reproducible, results with a higher level of stability and prolonged efficacy.

Effect of temperature on prism sensitivity

To understand the effect of temperature on the prism sensitivity and to further validate the surface topography consideration, the temperature dependence of the model was capitalized

(a) Temperature evolution of $\partial R/\partial\theta$ curves for Cr adhesive layer prism. Vertical lines: working angles θ_w set before (42.25°) and after (42.5°) θ_{max} the angle maximizing the sensitivity.

(b) Temperature evolution of $\partial R/\partial\theta$ curves for Ti adhesive layer prism. Vertical lines: working angles θ_w set before (42.25°) and after (42.5°) θ_{max} the angle maximizing the sensitivity.

(c) Sensitivity $\partial R/\partial n$ variations with temperature for Cr and Ti adhesive layer prism samples. The working angle θ_w was set to 42.5° experimentally, as the closest achievable angle to θ_{max} .

Figure 8: The effect of temperature on the sensitivity of the SPR imaging prisms and its relationship to the working angle θ_w .

upon. Four temperature points ($15^{\circ}C$, $25^{\circ}C$, $35^{\circ}C$ and $45^{\circ}C$) were studied, in accordance with experimental set-up limitations, to mimic *in-situ* variations in temperature. The working angle θ_w was set at 42.5° in our case, close to the maximized $\partial R/\partial \theta$. However, as seen in figures 8a and 8b the experimentally achievable θ_w was not equal to θ_{max} the angle maximizing the sensitivity. This resulted in a slight increase in the rate of loss of $\partial R/\partial n$ for sample 2 as θ_w was farther away of θ_{max} than for sample 1 (see Table 4). The models seemed to correlate well with experimentally obtained values, where sensitivities were calculated at the experimental working angle θ_w (figure 8c). Sample 1 showed a better fit with the theory, showing a maximum variation of $< 1\%$ from the experimental data. On the other hand, sample 2 performed a little worse, which was expected, due to its larger experimental variability. Nevertheless, the maximum theoretical variation was still only at 3%, this too at higher temperatures. This was a significant improvement from the initial 20% variation from our 4-layer (no effective layer) model. The rate of loss of $\partial R/\partial n$ with respect to an increase in temperature was seen to reduce by moving closer to θ_{max} (when $\theta_w > \theta_{max}$). For $\theta_w < \theta_{max}$, the relationship seems to reverse, with $\partial R/\partial n$ increasing with temperature (figure S9c). Temperature showed a more compounded relationship with sensitivity whereas for reflectivity measurements, at a constant θ_w , the signal was seen to drift, non-linearly; decreasing at $\approx 0.04\%/^{\circ}C$ for an increase in temperature (figure S9b). But even when θ_{max} was considered, the overall sensitivity of the system was seen to reduce slightly (figure S9c and S9a), with better sensitivities obtained at lower temperatures. This identified linear relationship could prove useful in temperature correction mechanisms in the opto-eN, however, a better alternative seems to be a new calibration of the working angle θ_w close to θ_{max} for *in-situ* temperature changes larger than $10^{\circ}C$.

Conclusion

In this study, we have first established a novel method in characterizing the optical performance of SPR imaging prisms in gas phase that is independent of the nature of the carrier gases. This is significant, as it would allow for a robust performance measure used for calibration of the prism and the subsequent immobilized sensor array of the opto-eNs; while also enabling the accurate compensation for environmental variation of the carrier gas, which is especially relevant for real world measurements that vary seasonally and regionally. Secondly, using this sensitivity parameter, the effect of two different adhesive layers, namely Cr and Ti were studied. For a 4-layer model, at similar adhesive layer thicknesses, Ti based prisms showed higher performances. However, significant sensitivity losses were observed, which were attributed to surface topography damping effects caused by regular grain structures. To characterize these structures, a novel 5-layer model was considered incorporating the surface roughness via the mMGT as a new effective layer. This experimentally validated model, showed the importance of the adhesive layer associated grains on the Au surface. The characterization of the effective layer structure from AFM measurements allows for the 5-layer model predictions to compare quantitatively with the experimental results, free from any fitting parameter. In this regards, Ti based prisms showed a larger loss in sensitivity due to their grain geometry and its relative volume fraction, which were experimentally verified. Even though higher sensitivities could still be achieved with Ti based prisms, a higher variability and drift could lead to reproducibility issues compared to the Cr counterparts. Thirdly, a temperature based validation was carried out, showing a decrease in overall prism sensitivity with an increase in temperature. Finally, it is important to mention that the model developed in this study could be further expanded upon, to aid in optimizing other multi-layer metal structures and their surface topographies for SPR imaging; to better match theory with experimental realities.

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Supporting Information Available

Additional figures illustrating SPR imaging sensitivities and AFM measurements and analyses. Transfer matrix method and implementation of the theoretical models.

Click [here](#) to view the supporting information

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Graphical TOC Entry